

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant:	Hiroaki Niimi	Art Unit	2823
Serial No.	09/885,744	Examiner	Nguyen
Filed:	06/20/2001		TI-32705
For:	Method For Annealing Ultra-Thin, High Quality Gate Oxide Layers Using Oxidizer/Hydrogen Mixtures		

AMENDMENT

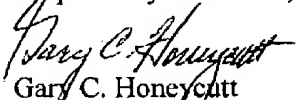
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Please amend the application as follows:

Cancel claims 8 and 14-16.

Respectfully submitted,


Gary C. Honeycutt
Attorney for Applicant
972-470-0130
April 30, 2004